L Number	Hits	Search Text	DB	Time stamp
-	1815	(phase adj shift\$3 same (mask or photomask	USPAT;	2003/04/30 14:30
		or reticle)) same (resist or photoresist	US-PGPUB;	
		or photosensit\$4)	EPO; JPO;	
		•	IBM TDB	
_	798	((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:37
	1	photomask or reticle)) same (resist or	US-PGPUB;	
	1	photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM_TDB	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
	, , , ,	overla\$5)		
-	126	1 ' ' ' ' ' ' ' ' ' ' ' ' ' ' ' ' ' ' '	USPAT;	2003/04/28 16:25
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
	.	or ((mask or photomask or reticle) near3	IBM_TDB	
		set) or (second or complementary) adj		
	į	(mask or photomask or reticle) or overla\$5)) and (transistor near3 gate or		
~		gate adj shr?nk\$3)		
_	97	((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:25
		photomask or reticle)) same (resist or	US-PGPUB;	2000,04,20 10.20
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
]		or ((mask or photomask or reticle) near3	IBM TDB	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)		
-	89	(((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:26
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM_TDB	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or gate adj shr?nk\$3)) and (resolution or		
	į	resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
	.	defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))		
-	65	((((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:28
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM_TDB	
		set) or (second or complementary) adj		
	,	(mask or photomask or reticle) or		
	į	overla\$5)) and (transistor near3 gate or		
] .		gate adj shr?nk\$3)) and (resolution or		
	•	resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or defocus) same (expos\$3 or radia\$4 or		
				·
		<pre>irradia\$4 or light or illumina\$4))) and (dose or dosage or intensity)</pre>		
L		(dose or dosage or intensity)	<u> </u>	<u> </u>

Page 1

				1
-	24	, , , , , , , , , , , , , , , , , , ,	USPAT;	2003/04/28 16:28
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM_TDB	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
1		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))) not		
		(((((((phase adj shift\$3 same (mask or		
		photomask or reticle)) same (resist or photoresist or photosensit\$4)) and (trim		
		or ((mask or photomask or reticle) near3		
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
1		configurat\$3) or aperture or (wavelength		
[or coherenc\$1 or illumina\$4 or focus or		
	1	defocus) same (expos\$3 or radia\$4 or		
	-	irradia\$4 or light or illumina\$4))) and		
		(dose or dosage or intensity))		
_	2	(("20020187636") or ("20020197543")).PN.	USPAT;	2003/04/28 16:33
			US-PGPUB;	
			EPO; JPO;	
			IBM TDB	
-	22	(("6284419") or ("6519501") or	USPAT;	2003/04/28 16:34
		("20020076622") or ("6453457") or	US-PGPUB;	
	İ	("6337172") or ("6541165") or ("6503666")	EPO; JPO;	
		or ("6162568") or ("6255024") or	IBM_TDB	1
		("6268091") or ("6319644") or ("6421111")	<u> </u>	
		or ("5972569") or ("5405721") or		
		("6042973") or ("6127096") or ("6374396")		
		or ("6096457") or ("6106979") or	•	
	1	("6040892") or ("6120952") or		,
		("5741624")).PN.		0000404455 5 5 5
_	21	(((("20020187636") or	USPAT;	2003/04/28 16:35
		("20020197543")).PN.) or ((("6284419") or	US-PGPUB	
		("6519501") or ("20020076622") or		
		("6453457") or ("6337172") or ("6541165")		
		or ("6503666") or ("6162568") or	1	
,		("6255024") or ("6268091") or ("6319644")	1	
		or ("6421111") or ("5972569") or		
		("5405721") or ("6042973") or ("6127096") or ("6374396") or ("6096457") or		
		("6106979") or ("6040892") or ("6120952")		
,		or ("5741624")).PN.)) not (((((phase adj		
		shift\$3 same (mask or photomask or		
		reticle)) same (resist or photoresist or		
		photosensit\$4)) and (trim or ((mask or		
		photomask or reticle) near3 set) or		
		(second or complementary) adj (mask or		
		photomask or reticle) or overla\$5)) and		
		(transistor near3 gate or gate adj		
		shr?nk\$3)) and (resolution or resolv\$3))		
		and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or	- 4	
		defocus) same (expos\$3 or radia\$4 or		
1		irradia\$4 or light or illumina\$4)))		1

	7	///20/5 211 212 210 204 206 255/52 22	HCDATT -	2002/05/12 10:00
-	398	((430/5,311-312,319,394,396 or 355/53,77 or 378/34-35 or 716/19-21).ccls. and	USPAT; US-PGPUB;	2003/05/13 18:22
		(phase adj shift\$3 same (mask or photomask	EPO; JPO;	
		or reticle)) same (trim or ((mask or	IBM TDB	
		photomask or reticle) near3 set) or	1011_100	
		(second or complementary) adj (mask or		
		photomask or reticle) or overla\$5)) not		
		((((((phase adj shift\$3 same (mask or		
		photomask or reticle)) same (resist or		
		photoresist or photosensit\$4)) and (trim		
		or ((mask or photomask or reticle) near3		
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4)))		
- ·	4	(("5885734") or ("6077630") or	USPAT;	2003/04/,28 18:09
		("20010000240") or ("20010028985")).PN.	US-PGPUB	
-	48	(("4037918") or ("4456371") or ("5302477")	USPAT;	2003/04/30 14:58
		or ("5308741") or ("5316878") or	US-PGPUB	
		("5324600") or ("5328807") or ("5334542")		
		or ("5352550") or ("5364716") or		
		("5424154") or ("5480746") or ("5496666")		
		or ("5498579") or ("5503951") or		
		("5523186") or ("5527645") or ("5532090")		1
		or ("5537648") or ("5538815") or		
		("5539568") or ("5565286") or ("5573890")		
		or ("5595843") or ("5620816") or		
		("5635316") or ("5636131") or ("5702848")		
		or ("5725969") or ("5761075") or		
		("5766804") or ("5766806") or ("5807649")		
		or ("5827623") or ("5858580") or		
		("5885734") or ("5923566") or ("5994002")		
		or ("5998068") or ("6004702") or		
		("6010807") or ("6057063") or ("6066180")		
	·	or ("6077630") or ("6083275") or		
		("6228539") or ("6251549") or		
		("6258493")).PN.		
_	9	(("5472814") or ("5923562") or ("6130012")	USPAT;	2003/04/30 15:02
		or ("6139994") or ("6185727") or	US-PGPUB	2303/04/30 13.02
		("6335128") or ("6338922") or	35 26105	
		("20010000240") or ("20010028985")).PN.		
1_	12	(("6420074") or ("6436590") or	USPAT;	2003/04/30 15:06
1	12	("20020083410") or ("20020122994") or	US-PGPUB	2003/04/30 13.00
		("20020127479") or ("20020122994") or	US-FGFUB	,
		("20020127479") of (20020129327") of ("20020142231") or		
		("20020142232") or ("20020142231") or		
		("20020142232") or ("20020144232") or ("20020155363")).PN.		
	6		USPAT;	2003/05/08 17:54
-	6	((full or complete or overall) adj phase		2003/03/08 17:54
		adj shift\$3 adj (mask or reticle or	US-PGPUB;	
		photomask) same (resist or photoresist))	EPO; JPO;	
		and 430/5.ccls.	IBM TDB	2002/05/22 16 16
-	1	("6524752").PN.	USPAT;	2003/05/08 16:46
		((5.3)	US-PGPUB	0000 405 400 55 55
_	4	((full adj phase adj shift\$3 or full adj	USPAT;	2003/05/08 16:56
		<pre>phase) adj (mask or reticle or photomask))</pre>	US-PGPUB;	
		not (((full or complete or overall) adj	EPO; JPO;	
		phase adj shift\$3 adj (mask or reticle or	IBM_TDB	
		<pre>photomask) same (resist or photoresist))</pre>		
		and 430/5.ccls.)		

	355			0002/05/12 10 40
-	357	((dose or dosing or dosage or intensity)	USPAT;	2003/05/13 18:49
		same (second adj (mask or photomask or	US-PGPUB;	
		reticle))) not	EPO; JPO;	
		(((430/5,311-312,319,394,396 or 355/53,77	IBM_TDB	
		or 378/34-35 or 716/19-21).ccls. and		
		(phase adj shift\$3 same (mask or photomask		
		or reticle)) same (trim or ((mask or		
		photomask or reticle) near3 set) or		
1		(second or complementary) adj (mask or		
		photomask or reticle) or overla\$5)) not		
		(((((phase adj shift\$3 same (mask or		
		photomask or reticle)) same (resist or		
		photomask of recteley, same (resist of photoresist or photosensit\$4)) and (trim		
		or ((mask or photomask or reticle) near3		
		1		
		set) or (second or complementary) adj		1
		(mask or photomask or reticle) or		
	1	overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or	ĺ	
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))))		
-	16	(((dose or dosing or dosage or intensity)	USPAT;	2003/05/13 18:51
		same (second adj (mask or photomask or	US-PGPUB;	,
		reticle))) not	EPO; JPO;	
		(((430/5,311-312,319,394,396 or 355/53,77	IBM TDB	
		or 378/34-35 or 716/19-21).ccls. and	_	
1		(phase adj shift\$3 same (mask or photomask		
		or reticle)) same (trim or ((mask or		
		photomask or reticle) near3 set) or		
:		(second or complementary) adj (mask or		i
		photomask or reticle) or overla\$5)) not		
		(((((phase adj shift\$3 same (mask or		
		photomask or reticle)) same (resist or		
ĺ		photomask of reticie// same (resist of photoresist or photosensit\$4)) and (trim		
		or ((mask or photomask or reticle) near3		
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		İ
		or coherenc\$1 or illumina\$4 or focus or		
	1 .	defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))))) and		
		(resist or photoresist) and phase adj		
		shift\$3 same (mask or photomask or		
		reticle)		